





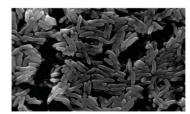
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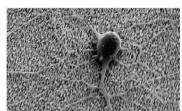
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 - Coater
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 - Holder - Filament
 - Critical Point Dryer
 - Freeze Dryer
 - Cool Stage
 - Polishing Machine
 - Mounting Machine
 - 3D Reconstruction SW

01 Applications



Life Science

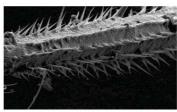




Neuror



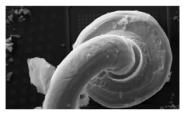
Insect(Fly's head)



Insect(Fly's leg)



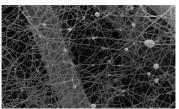
Electronics



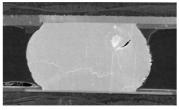
Wire bonding



Printed Circuit



Nano Fiber

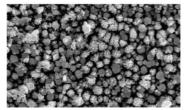


Semiconductor Package





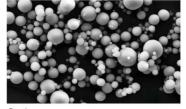
Material Science

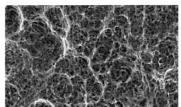




Cadmium Oxide

Fabrio



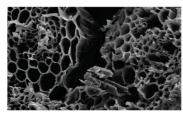


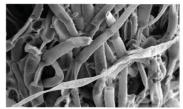
Powde

Dental Implant



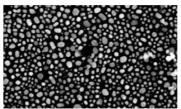
Natural Resource





Leaf Cross Section

Stamen





Gold Powder

Cross section of a tree

02 Tabletop SEM Cube-Series

- Most Affordable and Portable
- Full 5-Axis Euccentric Stage
- Integrated EDS System

Magnification	x20 ~ x200,000	
Stage	X,Y: 40mm / Z: 5~20mm / T:-20~20° / R: 360°	
Maximum Sample Size	60mm(H), 30mm(V)	





Space Efficiency

Cube-series is most compact Tabletop SEM in the world for its portability and space efficiency. Users can move their SEM by themselves by following the Customer Services directions.



5-Axis Euccentric Stage

Cube-series is the only Tabletop SEM which provides 5-axis euccentric stage[motorized or manual] in the world. Euccentric tilt is essential for 3D reconstruction function.



More Affordable Solution

Each laboratory can own its SEM and EDS system on its budget. EmCrafts' Cubeseries is a highly customizable system so that each laboratory can configure its own system. Please contact our sales department for your requirements.





Installation Footprint



CUBE-Series specification

Model	Cube-1000	Cube-1100	Cube-1000A	Cube-1100A
Stage	5-axis Manual X,Y: 40mm (-20mm Z: 5 ~ 20mm / T: -20	~ 20mm) J ~ 20° / R : 360°	3-axis Motorized X,Y: 40mm (-20mm 2-axis Manual Z:5~20mm/T:-2	
Variable Pressure	X	0	Х	0
Vacuum Mode	High Vacuum only (<9×10 ⁻³ Pa)	High Vacuum Mode (<9×10 ⁻³ Pa) Low Vacuum Mode (10~230Pa)	High Vacuum only (<9×10 ⁻³ Pa)	High Vacuum Mode (<9×10 ⁻³ Pa) Low Vacuum Mode (10-230Pa)
Vacuum System	Fully Automated Eva -Turbo molecular pu -Rotary vane pump -Electrical valve syst	mp (Vacuum ready within 3 minutes	s)	
Electron Gun	Precentered Tungste	n Filament		
Detector	SE (ET-type)	SE (ET-type) BSE (4channel, Semiconductor)	SE (ET-type)	SE (ET-type) BSE (4channel, Semiconductor
Resolution	5.0nm (SE Image)	5.0nm (SE Image) 6.0nm (BSE Image)	5.0nm (SE Image)	5.0nm (SE Image) 6.0nm (BSE Image)
Magnification	x20~x200,000			
Acceleration Voltage	500V ~ 30kV			
Objective IRIS	20/20/50/100µm (Variable aperture)			
Image Shift	±50µm			
Maximum Sample Size	Horizontal: 60mm, Vertical: 30mm			
Advanced Scan Mode	Dynamic Focus, Point & Line Scan, Tilt Compensation			
Working Distance	0-20mm			
Automatic Function	Auto Brightness/Contrast, Auto Focus, Auto Gun Alignment, Auto Saturation, Auto Filament / Bias			
Image Format	JPG, TIFF, BMP, PNG			
Display Mode	Focus Mode : 320x24 Preview Mode : 800x Slow Mode : Applical Photo Mode : Up to 3	600 ble to both preview and focus mode		
Dimension(mm)	Installation Dimension : 1200(W) x 600(D) - Main System : 400(W) x 500(D) x 580(H) - Control Box : 500(W) x 260(D) x 370(H)			
Supplied Accessories	Factory-centered Filament Cartridge 1box(10units), Specimen Mounts 1box(10units), Tweezer, Carbon Tape, Hex. Driver 0.89mm (1 ea.), Hex. T Wrench 2.5mm (2 ea.)			
Operation Device	Windows 10-based All-in-One 21.5" Workstation -100% controlled by keyboard and mouse			
Optional Devices	Chamber Camera LaBs/CeBs upgrade 3D Imaging EDS(Cube-1000X All-in-one Model of SEM-EDS) E-beam Lithography			
Power Supply	Single Phase : 100 ~	240VAC, 50/60Hz, 1kVA		



03 Compact SEM Genesis-Series

- 5-Axis Euccentric Stage
- More Value in Less Space
- Straightforward &Intuitive Manual Stage (Genesis-1000 / 1100)
- More Versatile 5-Axis Motorized Stage (Genesis-2020 / 2120)
- Observation of Non-Conductive Sample (Genesis-1100 / 2120)

Genesis series is a high-performance W-filament SEM with x300K magnification and 3nm resolution

High performance and versatility are integrated in a stylish design which is the most compact of the world in the same category.

EmCrafts-Patented vacuum system enables faster specimen exchange. (within 3min.)

Universal extension ports are available for future upgrade and user customization.

Due to factory-centered filament cartridge, filament exchange is easy and quick.

Images are saved in various formats and can be easily restored for annotation simply by clicking on the thumbnails.



Cost-Effectiveness

- · Genesis series are most affordably priced
- · Perfect solution for any laboratory



Easy Maintenance

- Filament Burn out Notification
- Precentered Filament
- Only 1~2 Minutes are Required for a Filament Replacement
- Remote Diagnostics
 Electrical Checkpoints are Probed and Reported



Genesis 1000/1100

- Intuitive 5-axis manual euccentric stage on Genesis-1000/1100 provides easy and straightforward way to move specimens.
- Variable pressure capability of Genesis-1100 enables users to observe non-conductive samples such as biological samples.

Magnification	x10 ~ x300,000	
X,Y: 40mm / Z: 5~45mm / T:-20~90°/ R: 360°		
Maximum Sample Size	96mm(H), 50mm(V)	

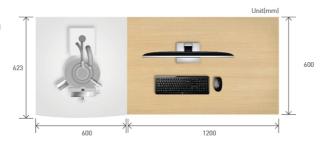
Genesis 2020/2120

- Genesis-2020/2120 provides 5-axis motorized euccentric stage in the same compact design.
- Intuitive "Point & Go" operation enables effortless stage movement in a quick manner.
- Position save and restore function is useful especially for multi-specimen mount.

Magnification	x10 ~ x300,000	
Stago	X : 90mm, Y : 60mm / Z : 5~60mm /	
Stage	T :-20~90°/ R : 360°	
Maximum Sample Size	150mm(H), 60mm(V)	



Installation Footprint





GENESIS-Series specification

S-axis Manual X-40mm -20mm 20mm X-90mm 4-65mm -45mm -45mm -20mm X-90mm -20mm X-90mm -20mm X-90mm -20mm X-90mm -45mm -30mm X-90mm -20mm X-90mm X-90m	Model	Genesis-1000	Genesis-1100	Genesis-2020	Genesis-2120
Vacuum Mode	Stage	X : 40mm [-20mm · Y : 40mm [-20mm · Z : 5 ~ 45mm T : -20° ~ 90°		X : 90mm (-45mm Y : 60mm (-30mm Z : 5 ~ 60mm T : -20 ~ 90°	
Vacuum Mode (4.9×10³Pa) Low Vacuum Mode (10-230Pa) (-9×10³Pa) Low Vacuum Mode (10-230Pa)	Variable Pressure	X	0	Χ	0
Turbo molecular pump Vacuum ready within 3 minutes	Vacuum Mode				
Detector SE[ET-type] SE[ET-type] BSE[Achannel, Semiconductor] SE[ET-type] BSE[Achannel, Semiconductor] SE[ET-type] BSE[Achannel, Semiconductor] 3.0nm [SE Image] 3.0nm [SE Image] 3.0nm [SE Image] 5.0nm [BSE Image] 5.0nm	Vacuum System	- Turbo molecular pump(Vacuum ready within 3 minutes) - Rotary vane pump			
BSE[4channel, Semiconductor] BSE[4channel, Semiconductor] SE[E1-type] BSE[4channel, Semiconductor]	Electron Gun	Precentered Tungs	ten Filament		
Magnification x10 ~ x300,000 x10 ~ x	Detector	SE(ET-type)		SE(ET-type)	
Acceleration Voltage Objective IRIS Objective IRIS 20/20/50/100µm{ Variable aperture} ### ### ### ### #### ###############	Resolution	3.0nm (SE Image)		3.0nm (SE Image)	
Display Mode South Mode Display Mode Displa	Magnification	x10 ~ x300,000			
Image Shift	Acceleration Voltage	200V ~ 30kV			
Maximum Sample Size Advanced Scan Mode Dynamic Focus, Point & Line Scan, Tilt Compensation O-45mm O-60mm Automatic Function Auto Brightness/Contrast, Auto Focus, Auto Gun Alignment, Auto Saturation, Auto Filament / Bias Image Format JPG, TIFF, BMP, PNG Focus Mode: 320x240 pixel, Resizable Preview Mode: 800x600 Slow Mode: Applicable to both preview and focus mode Photo Mode: Up to 3200x2400 Installation Dimension: 1800(W) x 600(D) - Main System: 600(W) x 623(D) x 1250(H), 130Kg - Rotary Pump: 454(W) x 134(D) x121(H), 22Kg Supplied Accessories Operation Device Optional Devices Optional Devi	Objective IRIS	20/20/50/100µm(Variable aperture)			
Advanced Scan Mode Working Distance O-45mm O-60mm O-60mm Auto Brightness/Contrast, Auto Focus, Auto Gun Alignment, Auto Saturation, Auto Filament / Bias Image Format JPG, TIFF, BMP, PNG Focus Mode : 320x-240 pixel, Resizable Preview Mode : 800x-600 Slow Mode : Applicable to both preview and focus mode Photo Mode : Up to 3200x-2400 Installation Dimension : 1800(W) x 600(D) - Main System: 600(W) x 623(D) x 1350(H), 130Kg - Rotary Pump : 454(W) x 134(D) x121(H), 22Kg Supplied Accessories Operation Device Optional Devices Optional Devices Opt	Image Shift	±50µm			
Working Distance Automatic Function Auto Brightness/Contrast, Auto Focus, Auto Gun Alignment, Auto Saturation, Auto Filament / Bias Image Format Display Mode Display Mode Display Mode Dimension(mm) Dimension(mm	Maximum Sample Size	Horizontal : 96mm, Vertical : 50mm Horizontal : 150mm, Vertical : 60mm			n, Vertical : 60mm
Automatic Function Image Format JPG, TIFF, BMP, PNG Focus Mode : 320x240 pixel, Resizable Preview Mode : 800x600 Slow Mode : Applicable to both preview and focus mode Photo Mode : Up to 3200x2400 Installation Dimension : 1800(W) x 600(D) - Main System: 600(W) x 623(D) x 135(D H), 130Kg - Rotary Pump : 454(W) x 134(D) x 121(H), 22Kg Supplied Accessories Factory-centered Filament Cartridge 1box (10units), Specimen Mounts 1box (10units), Tweezer, Carbon Tape, Hex. Driver 0.89mm (1 ea.), Hex. T Wrench 2.5mm (2 ea.) Windows 10 - based Alt-in- One 21.5" Workstation -100% controlled by keyboard and mouse EBSD[Electron Back Scattered Diffraction) EDS[Energy Dispersive Spectroscopy) WDS[Wavelength Dispersive Spectroscopy) CL(Cathodoluminescent) Imaging Chamber Camera LaBx/CeBx Upgrade 3D Imaging Raman Spectroscopy E-beam Lithography	Advanced Scan Mode	Dynamic Focus, Point & Line Scan, Tilt Compensation			
Display Mode	Working Distance	0~45mm 0~60mm			
Focus Mode : 320x240 pixel, Resizable Preview Mode : 800x600 Slow Mode : Applicable to both preview and focus mode Photo Mode : Up to 3200x2400	Automatic Function	Auto Brightness/Co	ontrast, Auto Focus, Auto Gun Ali	gnment, Auto Satura	tion, Auto Filament / Bias
Preview Mode : 800×600	Image Format	JPG, TIFF, BMP, PN	G		
Dimension(mm)	Display Mode	Preview Mode : 800 Slow Mode : Applic	l×600 able to both preview and focus m	ode	
Operation Device Hex. Driver 0.89mm [1 ea.], Hex. T Wrench 2.5mm [2 ea.] Windows 10 -based All-in-One 21.5" Workstation -100% controlled by keyboard and mouse EBSD[Electron Back Scattered Diffraction] EDS[Energy Dispersive Spectroscopy) WDS[Wavelength Dispersive Spectroscopy] CL(Cathodoluminescent) Imaging Chamber Camera LaBx/CeBx Upgrade 3D Imaging Raman Spectroscopy E-beam Lithography	Dimension(mm)	- Main System: 600(W) x 623(D) x 1350(H), 130Kg			
Uperation Device -100% controlled by keyboard and mouse EBSD(Electron Back Scattered Diffraction) EDS(Energy Dispersive Spectroscopy) WDS(Wavelength Dispersive Spectroscopy) CL(Cathodoluminescent) Imaging Chamber Camera LaBx/CeBx Upgrade 3D Imaging Raman Spectroscopy E-beam Lithography	Supplied Accessories				
EDS(Energy Dispersive Spectroscopy) WDS(Wavelength Dispersive Spectroscopy) CL(Cathodoluminescent) Imaging Chamber Camera LaBk/CeBk Upgrade 3D Imaging Raman Spectroscopy E-beam Lithography	Operation Device				
Power Supply Single Phase: 100 – 240VAC, 50/60Hz, 1kVA	Optional Devices	EDS(Energy Dispersive Spectroscopy) WDS(Wavelength Dispersive Spectroscopy) CL(Cathodoluminescent) Imaging Chamber Camera LaBi/CeBi Upgrade 3D Imaging Raman Spectroscopy			
	Power Supply	Single Phase : 100 ~ 240VAC, 50/60Hz, 1kVA			

04 Big Chamber SEM Veritas-Series

- High Performance and Productivity
- Large Scale Stage Movement

Veritas-series has 5-Axis euccentric motorized stage to provide easier measurement of large scale samples.

Magnification	x10 ~ x300,000	
Stage	X,Y: 120mm / Z: 5~65mm / T:-20~90°/ R: 360°	
Maximum Sample Size	210mm(H), 65mm(V)	



Application



Large Samples Analysis

Veritas-series can analyze large-scale samples conventional SEMs cannot. ex : Wafer, disk



Non-destructive Samples Analysis

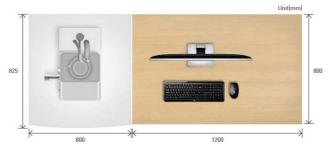
Able to analyze samples without cutting ex: PCB, Semiconductor pattern Analysis



Heavy Samples Analysis

Able to analyze heavy samples up to 2kg ex: Rock, Iron Ore





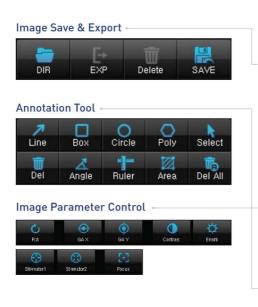


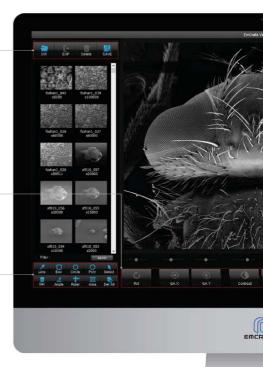
VERITAS-Series specification

Model	Veritas-3000 Veritas-3100		
Stage Type	5-axis Motorized X,Y: 120mm[-60mm~60mm] Z: 5-65mm T: -20°-90° R: 360°		
Variable Pressure	Χ 0		
Vacuum Mode	High Vacuum Mode (<9×10³Pa) High Vacuum Mode (<9×10³Pa) Low Vacuum Mode[10 ~ 230Pa]		
Vacuum System	Fully Automated Evacuation System - Turbo molecular pump (Vacuum ready within 3 minutes) - Rotary vane pump - Electrical valve system		
Electron Gun	Precentered Tungsten Filament		
Detector	SE Detector SE Detector BSE Detector (4channel, Semicondur		
Resolution	3.0nm (SE Image)	3.0nm (SE Image) 5.0nm (BSE Image)	
Magnification	x10 ~ x300,000		
Acceleration Voltage	200V ~ 30kV		
Objective IRIS	20/20/50/100µm (Variable aperture)		
Image Shift	±50μm		
Maximum Sample Size	Horizontal: 210mm, Vertical: 65mm		
Advanced Scan Mode	Dynamic Focus, Point & Line Scan, Tilt Compensation		
Working Distance	0 ~ 65mm		
Automatic Function	Auto Brightness/Contrast, Auto Focus, Auto Gun Alignment, Auto Saturation, Auto Filament / Bias		
Image Format	JPG, TIFF, BMP, PNG		
Display Mode	Focus Mode : 320x240 pixel, Resizable Preview Mode : 800x600 Slow Mode : Applicable to both preview and focus mode Photo Mode : Up to 3200x2400		
Dimension(mm)	Installation Dimension : 2000(W) x 800(D) -Main System : 800(W) x 825(D) x 1500(H), 200kg -Rotary Pump : 454(W) x 134(D) x 212(H), 22kg		
Supplied Accesscries	Factory-centered Filament Cartridge 1box[10units], Specimen Mounts 1box[10units], Tweezer, Carbon Tape, Hex. Driver 0.89mm (1 ea.), Hex. T Wrench 2.5mm (2 ea.)		
Operation Device	Windows 10-based All-in-One 21.5" Workstation I 100% controlled by keyboard and mouse		
Optional Devices	Chamber Camera LaBs/CeBs upgrade 3D Imaging Raman Spectroscopy EDS(Energy Dispersive Spectroscopy) EBSD(Electron Back Scattered Diffraction) WDS(Wavelength Dispersive Spectroscopy) CL(Cathodoluminescence) Imaging E-beam Lithography		
Power Supply	Single Phase : 100 ~ 240VAC, 50/60Hz, 1kVA		

05 Virtuoso

Easy-to-Use Operation Software











Automatic Functions



Vacuum Control & Status Monitor



Observation Mode Selection





Various Image Formats JPEG, TIFF, BMP, PNG



Observation Mode

Focus Window Mode TV Mode Slow Scan Mode Photo Mode



Automatic Functions

Filament/Bias Brightness/Contrast Gun Alignment Focus Stigmator



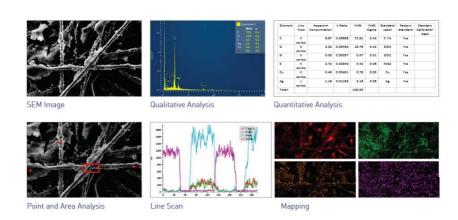
User Friendly Functions

Multi-User environment Wobble Filament burn-out alarm Customizable annotation

06 Optional Device

1. EDS SYSTEM

- . LN2-free operation, Silicon Drift Detector.
- · Detects elements from Be(4) to Cf(98).
- Premium Resdution of 129 eV is available.
- Quantitative Analysis, Qualitative Analysis, Multi-Point Analysis, LineScan, Mapping.
- EDS Maker: Oxford, Thermo, Bruker, EDAX, Evex.



2. ION SPUTTER COATER



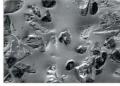
- . Operating principle: Top Electrode discharge system
- Ionization power: ~50mA(Max: 500V)
- Target: 50mm(Ø) x 0.1mm thick, Disc type(Au, Pt)
- Instrument case : 270(W) x470(D) x 385(H)
- Power requirements: 220V / Single phase AC 50/60Hz, 10A
- Weight: 22kg
- Rotary Pump : 16L/min[at 60Hz]



3. BSE Detector

- Semiconductor Type, 4 Channel Detector.
- BSE detector make it possible that sample with non-coating is observable and the boundary interface of alloy sample can be disentangled.







BSE Detector

SE Image

BSE Image

4. Holder









Multi Holder for 7 pin Stubs

Big Mount

45° Pin Stub Holder

Set Screw Vise

5. Filament





LaB₆ Filament

Factory-Centered Filament Cartridge

6. Critical Point Dryer

- Critical point dryer is an instrumental device which is used to preprocess biological specimens such as plants, insect, liver tissue, nerve cell, brain tissue etc.
- At critical point, the specimen is dried using CO₂. The original shape of specimen would be maintained and analyzed without causing surface tension by moisture and necrosis of biological tissue by dehydration.



7. Freeze Dryer

- Freeze dryer is to fix, dehydrate biological specimen with minimal shrinking and deformation.
- Electronic temperature control ranging from 0°C to 40°C. Rapid adjustment of temperature,10 minutes for adjustment from 40°C to 5°C.

8. Cool Stage

Cool stage offers a flexible heating/cooling to observe biological specimen. Biological specimen can be observed using cool stage with minimal dehydrationand deformation at lower temperature. Easily damaging Specimen by E-beam is also observable using cool stage.

9. Polishing Machine



The top of the range automatic polishing machines.

Powerful Fitted with powerful motors controlled by a frequency controller!

· Reproducible Built-in memory stores all your polishing

processes!

Efficent All the settings are completely adjustable

and programmable!

Simple Design and touch pad control!

Intelligent All the Technological experience

goes into the most complete polishing machine

on the market!



10. Mounting Machine

Emcrafts offers super short mounting times and maximum user-friendliness. Speed is further improved by using the optional dosing system.

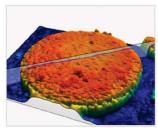


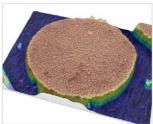
Powerful hydraulic system

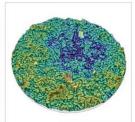
- Fast heating and cooling using new heating and cooling technology
- Available dual sample products with intermediate piston
- Two cylinder sample products available in different sizes
- · Requests for up to 4 sample products at once are possible
- 18 preset functions according to resin and mold size
- · Good sample product system with preheating
- · Faster cycle with optimized cooling system.

11. 3D Reconstruction S/W

Many nano-scale require depth information bet most optical microscope and scanning electron microscope
haven't delivered successful solutions so far. EmCrafts Products wupplies state-of-the-art 3D restruction
software which is capable of 3D imaging from multiple images at different angles or illuminations which can
replace expensive solutions such as atomic force microscope.





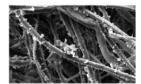


12. More advanced applications are available

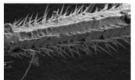
- EBSD(Electron Back Scattered Diffraction)
- WDS(Wavelength Dispersive Spectroscopy)
- CL(Cathodoluminescence) Imaging
- Chamber Camera
- Raman Spectroscopy
- · Etc.

Cube Series / Genesis Series / Veritas Series

Navigate, Explore, ... and Discover In Every Research Area









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